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OPEN A new kind of 2D topological **insulators BiCN with a giant gap and its substrate effects**

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Based on DFT calculation, we predict that BiCN, i.e., bilayer Bi films passivated with -CN group, is a novel 2D Bi-based material with highly thermodynamic stability, and demonstrate that it is also a new kind of 2D TI with a giant SOC gap (~1eV) by direct calculation of the topological invariant Z ₂ and obvious exhibition of the helical edge states. Monolayer h-BN and MoS₂ are identified as good **candidate substrates for supporting the nontrivial topological insulating phase of the 2D TI films, since the two substrates can stabilize and weakly interact with BiCN via van der Waals interaction and thus hardly affect the electronic properties, especially the band topology. The topological properties are robust against the strain and electric field. This may provide a promising platform for realization of novel topological phases.**

Two-dimensional (2D) topological insulators (TIs), aka quantum spin Hall (QSH) insulators, have attracted numerous interest in material science and condensed matter physics due to its scientific importance as an unique symmetry protected topological (SPT) quantum state and its potential technological applications ranging from spintronics to topological quantum computation^{1,2}. This novel electronic state has a bulk gap but can conducts charge and spin current without dissipation via the spin-momentum locked gapless edge state protected by time-reversal symmetry. The prototypical 2D TI was first proposed in graphene^{3,[4](#page-5-3)}, in which the spin-orbit coupling (SOC) opens a band gap at the Dirac points. However, the rather tiny second-order effective SOC makes the 2D TI state in graphene only appear at an unrealistically low temperatur[e5](#page-5-4)[,6](#page-5-5). So far, the QSH effect is only experimentally verified in HgTe/CdTe^{7,[8](#page-5-7)} and InAs/GaSb^{9[,10](#page-5-9)} quantum wells, in stringent conditions, e.g., ultrahigh-quality samples and ultralow temperature, due to their small bulk band gaps (at the order of meV). Therefore new 2D TIs with large bulk gaps which can realize QSH effect easily are still much desired.

Extensive effort has been devoted to the search for new QSH insulators with a large SOC gap¹¹⁻²⁷. For instance, honeycomb lattice type materials such as silicene, germanene^{[12](#page-5-11)} or stanene^{[13](#page-5-12)}, and chemically modified stanene^{[16](#page-5-13)} have been proposed. The element bismuth (Bi) has the largest SOC strength in the periodic table except radioactive elements. Therefore, the above exotic QSH effect can be expected to emerge notably in Bi-based materials. The bilayer Bi film has long been predicted as TI, with an inverted SOC gap of 0.2 eV at Γ point^{[11](#page-5-10)[,28](#page-6-0)[,29](#page-6-1)}, which can be described by BHZ model[7](#page-5-6) . In addition, chemical modification provides excellent control means to improve the key properties of systems with the relevant physics altered at the same time. For example, when the bilayer Bi films are hydrogenated or halogenated from both sides, the stable 2D honeycomb Bi hydride (Bismuthumane) and halide can be obtained, which can be described by modified Kane-Mele model^{3[,19](#page-5-14)}. The SOC gap at K and K' can reach the recorded 1 eV^{18,[19](#page-5-14)}, much larger than that of bilayer Bi films^{[28,](#page-6-0)29}. Besides, chemical group Methyl (-CH3) is used to modified the bilayer Bi fil[m22.](#page-5-16) Here we propose cyano (-CN) as another chemical group to tune the bilayer Bi film by passivating every Bi atom with a -CN group from both sides or one side. We find the two BiCN monolayers (regardless of the passivation from both sides or one side) are 2D TIs with a huge SOC gap of approximate 1 eV. The low-energy effective Hamiltonian is developed for the symmetric one (passivation from both sides). Moreover, we investigate monolayer h-BN and $MoS₂$ as candidate substrates, and find the composite systems are van der Waals (vdW) heterostructures.

Results

Structure and stability. The geometric structure of BiCN is shown in [Fig. 1\(a,b\)](#page-1-0). This new 2D material can be regarded as a freestanding high-buckled hexagonal bilayer Bi film functionalized by the cyano groups(-CN) from top and bottom sides. This functionalization will greatly modify the buckling structure and electronic

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Figure 1. Geometric structure and Phonon spectrum. (**a,b**) Optimized geometric structure of BiCN from top and side views. (**c**) Phonon spectrum of BiCN. (**d**) The FBZ (First Brillouin zone) and related high-symmetry k points.

Figure 2. Snapshot taken from MD simulation for 4×4 supercell of BiCN monolayer at temperature of 300 K (**a**) and 500K (**b**) after 2.3 ps.

properties as well. The optimized lattice constant of BiCN is 5.54*Å* and the buckling height of Bi atoms is only 0.25*Å*. The bond length of two nearest Bi atoms is 3.21*Å* and the out-plane bond length of Bi and -CN is 2.23*Å*. The computed phonon spectrum is shown in [Fig. 1\(c\).](#page-1-0) There are eighteen phonon modes for six atoms in the unit cell, but for a better view we here just show ten phonon modes with the lowest frequency. The absence of imaginary vibrational frequency over the whole First Brillouin Zone (FBZ) confirms the dynamic stability of this system.

The thermodynamic stability is also confirmed by first principle molecular dynamics (MD) simulations and the evaluation of formation energy. We use a 4×4 supercell to perform the MD simulation at 300 K and 500 K respectively. Random chosen samples of geometric structure after MD running for 2.3 ps are given in [Fig. 2.](#page-1-1) We can see the honeycomb skeleton of Bi atom is well maintained at 300K while the -CN functional groups have a little swing due to the thermal perturbation. Moreover, even at 500K, the structure of BiCN is still unbroken. The formation energy of BiCN is defined as $E_f=E_{BiCN}-n_BE_B_i-n_CE_C-n_NE_N$, where E_{BiCN} is the total energy of BiCN monolayer and E_{Bi} , E_C , E_N are the chemical potential of Bi, C, N atoms using bulk bismuth, diamond, nitrogen molecules, respectively. The $n_{B^p}n_C$ n_N are the numbers of Bi, C, N atoms in the BiCN unitcell. The calculated formation energy

of BiCN is about −8.18eV per unitcell, which is much larger then BiCH3(−0.52eV per unitcell)[22](#page-5-16), BiH(0.92eV per unitcell)^{[18](#page-5-15)}, BiF(−4.92 eV per unitcell)¹⁸, BiCl(−2.04 eV per unitcell)¹⁸, and BiI(−1.04 eV per unitcell). These indicate BiCN has the most highly thermodynamic stability among the functionalized Bismuth bilayers.

Electronic structure, topological properties and helical edge states. [Figure 3\(a\)](#page-2-0) shows the bandstructures of BiCN with SOC (red color) and without SOC (black color). In the absence of SOC, the system is a graphene-like Dirac semimetal with valence and conduction bands touching each other at the K (K′) points in the FBZ, forming Dirac cone with isotropic linearly dispersion relation. The Fermi level just crosses the Dirac points and make it a typical Dirac semimetal with the Fermi velocity $v_f = 7.6 * 10^5$ m/s. The atomic orbital projections of the band near the Dirac points show that the main band components come from the p_x/p_y orbitals of Bi atoms. It is greatly different from that of graphene whose Dirac cone is formed by the half-occupied p_z orbital in a honeycomb structure. When SOC is turned on, the original gapless Dirac cone is opened and the system becomes a TI with a huge non-trivial gap of 1.28 eV at K point and indirect gap of 1.04 eV between conduction band maximum (CBM) at Γ point and valence band maximum (VBM) at K point. Due to the existence of space inversion symmetry for BiCN system, we can simply calculate the topological invariant by the parity method proposed by Fu and Kane³⁰. The topological invariant index $\nu = 0$ indicates a topological trivial phase while $\nu = 1$ means a topological nontrivial phase. Here *ν* is define as

$$
(-1)^{\nu} = \prod_{i=1}^{4} \delta(k_i) = \delta(\Gamma) \delta(M)^3,
$$
 (1)

where $\delta(k_i) = \prod_{n \in val}^N \xi_{2n}^i$, ξ_{2n}^i is the parity of the 2nth occupied eigenstate at time-reversal invariant point (TRIP) *ki* , and N is the number of the Kramers pairs of valence bands. The parity table of twelve pairs of the occupied valence bands at Γ and three M points is shown in [Fig. 3\(b\).](#page-2-0) From total parities we obtain topological index *ν*= 1, which explicitly proves BiCN to be a 2D TI.

For structures with a finite boundary, 2D TIs have odd number pairs of helical edge states traversing the bulk band gap. These kinds of edge states can provide dissipationless conducting channels at boundary of a sample and be protected by the topological invariance. To further demonstrate the topological properties of BiCN system we calculate the electronic structure of its zigzag nanoribbon with width of 5.44 nm ($N = 12$). To eliminate the effect of dangling bonds on the edge, the marginal Bi atoms are saturated by hydrogen atoms. [Figure 3\(c\)](#page-2-0) displays the bandstructure of the zigzag nanoribbon. We can clearly see one pair of edge state (red lines) traverse

Figure 4. Optimized atomic structures of four composite systems with top view (top panel) and side view (bottom panel). (a) $\sqrt{3} \times \sqrt{3}$ BiCN on 4 \times 4 h-BN with lattice mismatch of −4.5% and interlayer distance of 3.01 Å (**b**) 1×1 BiCN on $\sqrt{3} \times \sqrt{3}$ MoS₂ with lattice mismatch of 0.6% and interlayer distance of 2.85 Å (**c**) 3 3 × *β*–BiCN on 4×4 with lattice mismatch of 0.5% and interlayer distance of 3.48*Å* (**d**) 1×1 *β*–BiCN on $\sqrt{3}$ × $\sqrt{3}$ MoS₂ with lattice mismatch of −4.8% and interlayer distance of 3.23 Å.

the bulk gap, cross each other and form a Dirac point at the middle of 1D BZ. Each state of the pair transports in opposite direction with filtered spin due to the protection of time reverse symmetry. Besides, the ribbon has two inversed-symmetric edges, so each edge state above has its degenerate copies for another edge. [Figure 3\(d\)](#page-2-0) depicts the charge density distribution of edge states near the Dirac point, which clearly shows they are well-localized along the edge of the ribbon.

In the following, we build a four-band model to capture the low-energy physics of BiCN. Akin to the bilayer Bi film with hydrogenated or halogenated from both side[s19,](#page-5-14) the symmetry-adopted basis functions can be written as linear combination of p_x and p_y orbitals of Bi atoms, i.e. $-\frac{1}{\sqrt{2}}(p_x^A + i\tau_z p_y^A)$, $\frac{1}{\sqrt{2}}(p_y^B - i\tau_z p_y^B)$ in the symmetric BiCN, with two distinct sites A and B in a unit cell, and τ_z as valley index (K or K[']). Expanding the Hamiltonian to the first order of k around K (K′) point, the symmetry-allowed four-bands low-energy effective model involving SOC can be written as

$$
H_{\tau} = \nu_F (k_x \sigma_x + \tau_z k_y \sigma_y) + \lambda_{so} \tau_z \sigma_z s_z,
$$
\n(2)

where Pauli matrix *σ*, *τ* and *s* denote A, B sublattices, valley index, and spin respectively. The second term is the on-site SOC, which exactly plays a crucial role to develop a topological nontrivial phase with a giant gap. The above low-energy effective Hamiltonian is invariable under the space inversion operation and the time reversal operation. The only two parameters v_f = 7.6 $*$ 10⁵m/s and λ_{so} = 0.64 eV are determined by fitting with the DFT calculations.

So far we have demonstrated BiCN to be a new kind of 2D TIs, and clarified the related physics. There are some advantages need to be emphasized here. Firstly, BiCN is saturated by cyano groups(-CN) on both sides, which may protect it from being destroyed by environment. Secondly, the giant non-trivial band gap is induced by the on-site SOC of Bi, very robust against the external strain and electric field as well as finite temperature (details at part II and I of Supplemental Material). Thirdly, the large gap of 1.04eV can effectively suppress the emergence of heat-activated carriers from bulk state and ensure the realization of QSH effects above room temperature. Besides, the giant gap will facilitate the localization of edge states and avoid the coupling of the edge states from different edges for narrow nanoribbons^{[33](#page-6-3)}. Last, with graphene-like hexagonal structure, the electronic structure of BiCN is valley related, which may have broad applications in valleytronics.

Substrate effects. Recently several 2D TIs are predicted, such as low-buckled silicene^{[12](#page-5-11)}, stanene^{[13](#page-5-12)}, bilayer-Bi film^{11,[14](#page-5-17),[15](#page-5-18)} and so on. However, for practical applications, these predicted 2D materials must be placed or grown on a substrate, which would influence the electronic structure and topological properties of the hosts^{[15](#page-5-18),[17](#page-5-19)}. So we specifically consider BiCN and its allotrope β –BiCN on monolayer h-BN and MoS₂. (Here β –BiCN can be regarded as a bilayer Bi film passivated by -CN from oneside not both sides shown in [Fig. 4\(c,d\)](#page-3-0). Detailed properties are provided in part III of Supplemental Material). As shown in [Fig. 4](#page-3-0) we construct four heterostructures composed of BiCN/*β*–BiCN and the substrates with structural mismatches less than 5%. The lattice constants of the substrates are fixed and the interlayer distances and atomic positions are relaxed to reach lowest energy structures with the vdW corrections.

To understand the interactions between BiCN/*β*–BiCN and the substrates, the adsorption energies, denoted as E*ad*=E*tot*− E*sub*− E*host*, are evaluated (where E*tot*, E*sub*, and E*host* are energies of the composite system, substrate, and BiCN/*β*–BiCN respectively). Here we calculate the dependence of the total energy E on the interlayer distance d with respect to the E_0 and d_0 at the equilibrium state, as plotted in [Fig. 5.](#page-4-0) When d- d_0 grows large enough, the $E_d - E_d$ will converges to a constant value, which is exactly the value of E_{ad} . Based on our calculation, the adsorption energies for BiCN on h-BN and $MoS₂$ are 7.78 and 8.82 meV/ $Å²$, which are close to the vdW interlayer binding energy of graphit[e31.](#page-6-4) The adsorption energies for *β*–BiCN on h-BN and MoS2 are 17.78 and

Figure 5. The absorption energy curve versus the interlayer distance. d_0 is the interlayer distance at equilibrium state. The two black straight dash line indicate the binding energies of graphene and monolayer MoS₂ separated from their bulks structure respectively.

Figure 6. Bandstructure for composite systems. In the bottom row (**e–h**) are the bandstructure of the four composite systems. The zero energy is set to be the Fermi level of each system. The red color and black color indicate the band contributed mainly from BiCN/*β*–BiCN layer and substrates respectively. In the top row (**a–d**) are the bandstructure of the pristine BiCN/*β*–BiCN in the same supercells as those of (**e–h**).

22.88 meV/ \AA^2 , which are smaller than that of MoS₂^{[20,](#page-5-20)32}. Hence both can be regarded as typical vdW-type heterojuctions. Comparing the BiCN and *β*–BiCN on substrates, the former has relatively smaller adsorption energy. Because both sides of the Bi layer in BiCN are protected by saturated -CN, which has weak interlayer interaction with substrates. For the *β*–BiCN case, since the Bi layer directly faces to the substrates, it has relatively stronger interlayer interaction than the former, but still in the vdW range.

Electronic structures for the four systems are listed in [Fig. 6\(e–h\)](#page-4-1). The red dot line represents the bands from BiCN/ β –BiCN and the black bands are derived from the substrates. As shown in [Fig. 6\(e,f\)](#page-4-1), the bandstructures of BiCN (red) and two substrates (black) BN and MoS₂ are separated without being mixed. The shape of band from BiCN layer in the composite system is the same as its pristine bandstructure in the same supercell, as shown in [Fig. 6\(a,b\)](#page-4-1). They are the same as the case of *β*–BiCN on MoS₂ ([Fig. 6\(d,h\)](#page-4-1)). Thus the topological properties of the BiCN on these substrates still keep invariant. It should be noticed that the fermi level crosses the valence band and conduction band from different parts of the heterojuctions and the whole systems become metallic. However we'll show that the metallic property is mainly caused by the large work function difference of BiCN/*β*–BiCN and the substrates, and the insulating property will recover when implying a proper gate voltage. The detailed process is discussed in part IV of Supplemental Material. The bandsturcture of the *β*–BiCN layer are well-located and

almost intact at middle of the large band gap of substrate h-BN, and as shown in Fig. $6(g,c)$, which indicate it is an ideal topological insulating vdW heterostructure.

Discussion

Based on DFT calculation, we predict that BiCN, i.e., bilayer Bi film passivated with -CN group, is a novel stable 2D Bi-based material, and demonstrate that it is also a new kind of 2D TI with giant SOC gap (~1 eV) by direct calculation of the topological invariant and clear plot of the helical edge states. Moreover, the low-energy effective Hamiltonian is given, and two candidate substrates are proposed. DFT calculation shows that the two substrates can stabilize and weakly interact with BiCN via vdW interaction and thus do not affect the electronic properties, especially the band topology of BiCN monolayer. Bilayer Bi film with a buckling honeycomb lattice has been manufactured through molecular-beam epitaxy^{[15](#page-5-18),[17](#page-5-19),[34](#page-6-6)}, and the topological edge states are observed as well³⁵. On the other hand, chemical functionalization of such 2D materials is a powerful tool to create new materials with desirable features. Although many cyanides are toxic, there are some environment friendly cyanation reagents, for example, application of a new catalytic system for cyanation reaction of various aryl halides using $K_4[Fe(CN)_6]$ as cyanating source has been feasible experimentally^{[36](#page-6-8)}, which indicates that $K_4[Fe(CN)_6]$ could also provide CNgroup for the manufacture of BiCN. Therefore, it is very promising that BiCN may be synthesized by chemical reaction in solvents or by exposure of bilayer Bi film to atomic or molecular gases. 2D TIs have been proved to be strong against disorder as long as *u*(1) gauge symmetry, and *T* symmetries are respected on average. Breaking any symmetry may induce an exotic phenomenon. A spontaneous magnetization can break *T* symmetry and yield two valley-polarized quantum anomalous Hall phases with a Chern number from −1 to 1, tunable by an external magnetic field orientation³⁷. A proximity coupling to a superconductor can break $u(1)$ gauge symmetry producing a Z_2 topological superconductor with a Majorana Kramers pair^{[38](#page-6-10)[,39](#page-6-11)}.

Methods

Our first principle calculations are carried out by the VASP (Vienna ab-initio simulation package)^{[40](#page-6-12)} within the generalized-gradient approximation (GGA) of Perdew, Burke, and Ernzerhof (PBE)[41](#page-6-13). The cutoff energy of plane wave basis is set as 500 eV for the calculations. The k-meshes of $15 \times 15 \times 1$ and $1 \times 15 \times 1$ are set for 2D unit cell and 1D nanoribbon calculations, respectively. The structures are relaxed with remaining force on each atoms less than 0.01 eV/*Å* and the self-consistent calculations are converged with energy difference less than 1meV/atom for two successive steps. A vacuum layer of 18*Å* was included in Z direction to avoid the interaction of its periodic image. The phonon spectrum is calculated by QUANTUM ESPRESSO⁴². The biaxial strain is implied by the change of lattice constant. The external vertical electric field is simulated by an artificially-implemented sawtooth potential in VASP. For considering substrate effects, the vdW interaction is included during the calculation by optB88-vdW correction⁴³.

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Author Contributions

B.F. performed the DFT calculations. B.F., C.-C.L., Y.G., W.G. and W.S. analyzed the data and wrote the paper. C.-C.L. designed and coordinated the project.

Additional Information

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